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# **Thermodynamics: Modeling and Simulation**

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Deadline for manuscript submissions:

closed (30 March 2022)

## **Message from the Guest Editors**

In this Special Issue, "Thermodynamics: Simulation and Modeling", we highlight and celebrate the latest developments in thermodynamics research. Topics include but are not limited to the following:

- Thermodynamic models for process modeling, simulation, optimization, and control: equations of state, excess Gibbs free energy models, and related methods;
- Property prediction for early stage process development and design: molecular simulation, electronic structure calculations, and groupcontribution methods;
- Molecular thermodynamics for process intensification.

We welcome contributions in the form of full-length articles, short communications, and reviews.











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## **Editor-in-Chief**

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## **Message from the Editor-in-Chief**

Processes (ISSN 2227-9717) provides an advanced forum for process/system-related research in chemistry, biology, material, energy, environment, food, pharmaceutical, manufacturing and allied engineering fields. The journal publishes regular research papers, communications, letters, short notes and reviews. Our aim is to encourage researchers to publish their experimental, theoretical and computational results in as much detail as necessary. There is no restriction on paper length or number of figures and tables.

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